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## **Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

- [1] (currently amended) A coating composition characterized by comprising: a polyalkylsilazane compound; an acetoxysilane compound; and an organic solvent.
- [2] (original) The coating composition according to claim 1, which further comprises a pore forming agent.
- [3] (original) The coating composition according to claim 2, wherein said pore forming agent is a copolymer comprising a siloxy-containing polyethylene oxide compound or a siloxy-containing polyethylene oxide compound as monomer units.
- [4] (currently amended) The coating composition according to any one of claims 1 to 3 claim 1, wherein said polyalkylsilazane compound comprises repeating units represented by general formula (1):

[Chemical formula 1]

$$\frac{\left( \stackrel{R^{2}}{\stackrel{\downarrow}{N}} \right)_{p} \stackrel{R^{1}}{\stackrel{\downarrow}{\stackrel{\downarrow}{N}} \stackrel{R^{4}}{\stackrel{\downarrow}{N}} r} \left( \stackrel{R^{4}}{\stackrel{\downarrow}{N}} \right)_{r}}{\left( \stackrel{\downarrow}{\stackrel{\downarrow}{N}} - \stackrel{R^{3}}{\stackrel{\downarrow}{N}} \right)_{q}}$$
(1)

wherein R<sup>1</sup> represents a hydrogen atom or an alkyl group having 1 to 3 carbon atoms, provided that all of R<sup>1</sup>s of the whole compound do not simultaneously represent hydrogen;

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R<sup>2</sup> to R<sup>4</sup> each independently represent a hydrogen atom or an alkyl group having 1

to 3 carbon atoms, provided that all of  $\,{\,{\sf R}^2}$  to  $\,{\sf R}^4$  do not simultaneously represent

hydrogen; and

p, q, and r each are 0 or 1 and  $0 \le p + q + r \le 3$ .

[5] (currently amended) A siliceous material characterized by being produced by

coating a coating composition according to any one of claims 1 to 4 claim 1 onto a

substrate or by filling a coating composition according to any one of claims 1 to 4 into a

frame or a groove, and firing the coating composition.

[6] (currently amended) A semiconductor device characterized by comprising a

siliceous material according to claim 5 as an intermetal dielectric.

[7] (currently amended) A process for producing a siliceous material, characterized

by comprising heating a coating composition according to any one of claims 1 to 4 claim 1

at a temperature of 350°C or below for 1 to 60 min.

[8] (new) The coating composition according to claim 1, wherein said

polyalkylsilazane compound further contains one or both groups represented by formulae

(2) and (3)

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$$-\frac{\binom{R^{8}}{N} - \binom{R^{9}}{1}}{\binom{R^{10}}{R^{11}}}$$
 (3)

wherein  $R^5$  to  $R^{11}$  each independently represent a hydrogen atom or an alkyl group having 1 to 3 carbon atoms, provided that both  $R^5$  and  $R^6$  do not simultaneously represent hydrogen and all of  $R^9$  to  $R^{11}$  do not simultaneously represent hydrogen.